IPAC'24 - 15th International Particle Accelerator Conference



Contribution ID: 1674 Contribution code: MOPR21

Type: Poster Presentation

Experimental investigation of zero transverse force modes in sub-THz dielectric lined waveguide

Monday, 20 May 2024 16:00 (2 hours)

Dielectric-lined waveguides have been extensively studied for high-gradient acceleration in beam-driven dielectric wakefield acceleration (DWFA) and for beam manipulations, including the application of zero transverse force modes in the waveguides. In this paper, we investigate the zero transverse force modes excited by a relativistic electron bunch passing through a dielectric waveguide with a rectangular transverse cross section. Numerical simulations were performed to optimize the start-to-end beamline using Opal-t, ELEGANT, and WARPX. A Longitudinal Phase Space (LPS) measurement system is used to understand the interaction of the beam with the waveguide modes, and analysis of the resolution of the LPS system was conducted. We will discuss preliminary experimental data collected at the Argonne Wakefield Accelerator (AWA) benchmarked with the simulation results.

Footnotes

Funding Agency

This is partially supported by DOE award DE-SC0022010 to NIU. The AWA facility is sponsored under DOE contract No. DE-AC02-06CH11357 with Argonne National Laboratory.

Paper preparation format

LaTeX

Region represented

North America

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Session Classification: Monday Poster Session

Track Classification: MC3: Novel Particle Sources and Acceleration Techniques: MC3.A16 Advanced Concepts